Markov jump transport of trapped charge in thin dielectric layers

Andrey Pil'nik (✉ a.pilnik@g.nsu.ru)

Institute of Semiconductor Physics

Andrey Chernov

Institute of Semiconductor Physics

Damir Islamov

Institute of Semiconductor Physics

Research Article

Keywords: Markov jump transport, charge transport

Posted Date: December 11th, 2020

DOI: <https://doi.org/10.21203/rs.3.rs-121844/v1>

License: © ⓘ This work is licensed under a Creative Commons Attribution 4.0 International License.

[Read Full License](#)

Markov jump transport of trapped charge in thin dielectric layers

Andrey A. Pil'nik^{1,2,*,+}, Andrey A. Chernov^{1,2,+}, and Damir R. Islamov^{1,2,+}

¹Rzhanov Institute of Semiconductor Physics, Siberian Branch of the Russian Academy of Sciences, Novosibirsk, 630090, Russian Federation

²Novosibirsk State University, Novosibirsk, 630090, Russian Federation

*a.pilnik@g.nsu.ru

+these authors contributed equally to this work

ABSTRACT

In this study, we developed a discrete theory of the charge transport in thin dielectric films by trapped electrons or holes, that is applicable both for the case of countable and a large number of traps. It was shown that Shockley-Read-Hall-like transport equations, which describe 1D transport through dielectric layers, might incorrectly describe the charge flow through the ultra-thin layers with a countable number of traps, taking into account injection-from and extraction-to electrodes (contacts). A comparison with other theoretical models shows a good agreement. The developed model can be applied to one-, two- and three-dimensional systems. The model, formulated in a system of linear algebraic equations, can be implemented in the computational code using different optimized libraries. We demonstrated that analytical solutions can be found for stationary cases for any trap distribution and for dynamics of system evolution for special cases. These solutions can be used to test the code and for studying of charge transport properties of thin dielectric films.

Introduction

New dielectrics, like high- κ HfO_2 , Ta_2O_5 , ZrO_2 ^{1–5} and low- κ ones^{6–9} are extremely perspective materials for using them in modern and future electronic devices, including memory and digital ones. That is why the knowledge about charge transport processes and mechanisms in dielectrics is critical for modern microelectronics. High- κ dielectrics are promising materials for resistive random access memory (RRAM), ferroelectric random access memory (FRAM) and memristor devices, while low- κ dielectrics are the insulating dielectrics that separate wire interconnects and transistors from each other in high-speed integrated circuits⁶. High- κ -based MOSFETs, FRAM and flash memories and low- κ interconnect separators need dielectrics with low leakage currents, while RRAM devices exhibit better performance when used dielectric layers are mostly nonstoichiometric, i.e. include a lot of defects and traps^{10–12}. That is why producing high-quality electronic devices requires hard control of deposited dielectric films quality to monitor leakage currents.

The charge currents in metal-insulator-semiconductor (MIS) and metal-insulator-metal structures (MIM) might be limited by a contact metal-insulator or insulator-semiconductor (contact-limited currents) or by the traps in the insulator bulk (bulk- or trap-limited currents). Contact-limited current models describe electron and hole emission from semiconductor or metal electrodes to traps (localized states in the bandgap) or to the conduction band in dielectrics. The quantum field emission, first proposed by R. Fowler and L. Nordheim, describes charge carriers tunnelling through a triangle energy barrier to the dielectric conduction band and does not depend on the temperature¹³. At high temperatures a significant contribution to the transport might give thermally assisted tunnelling^{14,15} and field-enhanced thermionic emission of hot carriers (Schottky effect)¹⁶. The direct tunnelling from one electrode to another through a trapeze barrier takes place in structures based on ultra-thin (< 5 nm) dielectric films¹⁷.

Bulk-limited charge transport models can be divided into two large subgroups: isolated trap ionisation (Frenkel model^{18,19}, multiphonon single trap ionization proposed by S. Makram-Ebeid and M. Lannoo²⁰) and hops between neighbour traps (thermally assisted traps between Coulomb overlapped centres^{21,22}, phonon-assisted tunnelling of electrons (holes) between neighbouring traps²³).

In essence all these models give the probabilities of hop between two traps and between a trap and an electrode. Usually, a set of approaches was used to describe the charge transport between traps in dielectric layers using these probabilities. One on them is time-dependent direct or Monte-Carlo simulations with hops between traps, and it requires carrying out many simulations to obtain sufficient statistics for averaging in order to identify general patterns. Another approach is discrete

Shockley-Read-Hall-like (SRH) 1D transport equations with the boundary conditions^{23,24}:

$$\begin{aligned}\frac{d\bar{n}_\alpha}{dt} &= \bar{n}_{\alpha-1}(1-\bar{n}_\alpha)H_{\alpha-1,\alpha} - \bar{n}_\alpha(1-\bar{n}_{\alpha-1})H_{\alpha-1,\alpha} + \bar{n}_{\alpha+1}(1-\bar{n}_\alpha)H_{\alpha+1,\alpha} - \bar{n}_\alpha(1-\bar{n}_{\alpha+1})H_{\alpha,\alpha+1} + G_\alpha - R_\alpha; \\ \frac{d\bar{n}_1}{dt} &= (1-\bar{n}_1)I_1 - \bar{n}_1E_1 + \bar{n}_2(1-\bar{n}_1)H_{2,1} - \bar{n}_1(1-\bar{n}_2)H_{1,2} + G_1 - R_1; \\ \frac{d\bar{n}_N}{dt} &= (1-\bar{n}_N)I_N - \bar{n}_NE_N + \bar{n}_{N-1}(1-\bar{n}_N)H_{N-1,N} - \bar{n}_N(1-\bar{n}_{N-1})H_{N,N-1} + G_N - R_N,\end{aligned}\quad (1)$$

where $\bar{n}_\alpha$ is the average filling of the α -th trap, t is the time, $H_{\alpha,\beta}$ is the probability rate of a hop from the α -th trap to the β -th one, G_α is the trapped carrier generation rate (due to free carriers localization) and R_α is the trapped carrier recombination rate (due to trap ionization to a conduction/valence band, recombination with free carriers with an opposite sign) and N is the trap number. In case of low free charge carriers density $n_t \gg n$ (here n_t is the trapped carrier density, n if the free carriers density), the terms G_α and R_α may be omitted due to their smallness. Recently, discrete equation (1) has been extended to a continuous model²⁵:

$$\frac{\partial \bar{n}}{\partial t} = -a \frac{\partial}{\partial x} \{ [H^+ - H^-] \bar{n}(1-\bar{n}) \} + \frac{a^2}{2} \frac{\partial}{\partial x} \left\{ [H^+ + H^-] \frac{\partial \bar{n}}{\partial x} \right\}, \quad (2)$$

where a is the distance between traps, x is the coordinate, $H^\pm = H(\pm F)$ are the hop rates between traps along and against electric field F . This approach is approximate, but it works fine for a large number of traps in a dielectric medium. Modern electronic devices are based on thin films with the feature size of several nanometers. In this case, the number of traps in dielectric bulk N is countable, and the filling averaging over them might give quite large deviations due to $\sqrt{N}/N = 1/\sqrt{N}$ law. The aim of the present work is the development of an exact universal model of trapped charge transport via a hopping between traps in strong electric fields applicable both for the case of countable and a large number of traps.

Results

Markov-jump-like (MJ) model formulation

Let us consider the volume of a dielectric containing N traps. From the classical standpoint (considering electrons to be strongly localized inside traps) there is a finite set of 2^N different variants of charge localization inside traps (states): $\mathbf{n}^1, \mathbf{n}^2, \dots, \mathbf{n}^{2^N}$. Each state $\mathbf{n}^\alpha$ has a certain probability of transition to state $\mathbf{n}^\beta$ during a short period of time δt , which we will indicate as $P_{\alpha,\beta}$. Obviously, the probability $P_{\alpha,\alpha}$ of not changing state $\mathbf{n}^\alpha$ can be obtained from the probabilities of all transitions from $\mathbf{n}^\alpha$: $P_{\alpha,\alpha} = 1 - \sum_{\beta \neq \alpha} P_{\alpha,\beta}$. Thus, the transition probability matrix $\hat{\mathbf{P}}$ sized $2^N \times 2^N$ can be compiled.

At each moment in time, the system can be characterized by the column vector $\mathbf{p} = [p_1; p_2; \dots; p_{2^N}]$ of probabilities, where p_α is the probability of finding the system in state $\mathbf{n}^\alpha$. The evolution of average state of the system during one time step δt can now be described by the expression $\mathbf{p}(t + \delta t) = \hat{\mathbf{P}}\mathbf{p}(t)$, which can be transformed to the form $\mathbf{p}(t + \delta t) - \mathbf{p}(t) = (\hat{\mathbf{P}} - \hat{\mathbf{I}})\mathbf{p}(t)$, where $\hat{\mathbf{I}}$ is the identity matrix. The differential form of describing the evolution of $\mathbf{p}$ can be achieved by considering the limit $\delta t \rightarrow 0$:

$$\frac{d\mathbf{p}}{dt} = \hat{\mathbf{Q}}\mathbf{p}, \quad \text{where} \quad \hat{\mathbf{Q}} = \lim_{\delta t \rightarrow 0} \frac{\hat{\mathbf{P}} - \hat{\mathbf{I}}}{\delta t}. \quad (3)$$

This equation is known as a Kolmogorov backward equation (KBE). The element $Q_{\alpha,\beta}$ of matrix $\hat{\mathbf{Q}}$ can be treated as the rate of transition from state $\mathbf{n}^\alpha$ to state $\mathbf{n}^\beta$ (so, $Q_{\alpha,\beta}\delta t$ is the probability of such a transition in short time δt). Diagonal elements can again be found from all of the rates of transition from the state $\mathbf{n}^\alpha$: $Q_{\alpha,\alpha} = -\sum_{\beta \neq \alpha} Q_{\alpha,\beta}$. The resulting differential equation (3) can be solved analytically:

$$\mathbf{p}(t) = \exp(\hat{\mathbf{Q}}t)\mathbf{p}(0). \quad (4)$$

If we represent the state $\mathbf{n}^\gamma$ as a column vector $\mathbf{n}^\gamma = [n_1^\gamma; n_2^\gamma; \dots; n_N^\gamma]$, where n_α^γ is the filling of the α -th trap in state γ (takes the value 0 if the trap is empty and the value 1 if a charge carrier is captured in the trap), then the ensemble average filling of traps $\bar{\mathbf{n}} = [\bar{n}_1; \bar{n}_2; \dots; \bar{n}_N]$ can be expressed as an average for all states according to their individual probability values:

$$\bar{\mathbf{n}}(t) = \sum_{\gamma=1}^{2^N} \mathbf{n}^\gamma p_\gamma(t) = \hat{\mathbf{N}}\mathbf{p}(t) = \hat{\mathbf{N}}\exp(\hat{\mathbf{Q}}t)\mathbf{p}(0),$$

where $\hat{\mathbf{N}}$ is the matrix of states such that $N_{\alpha,\beta}$ is the occupancy of the α -th trap in the β -th state.

Each option of filling traps $\mathbf{n}^\gamma$ is characterized by the matrix of currents $\hat{\mathbf{i}}^\gamma$, where $i_{\alpha,\beta}^\gamma$ is the current between the α -th and β -th traps in the state γ . Obviously, the matrix is skew-symmetric: $i_{\alpha,\beta}^\gamma = -i_{\beta,\alpha}^\gamma$. So, the matrix of currents can be expressed as an average for all states according to their individual probability values:

$$\hat{\mathbf{i}}(t) = \sum_{\gamma=1}^{2^N} \hat{\mathbf{i}}^\gamma p_\gamma(t).$$

The current between electrodes and traps can also be introduced into this matrix by adding the corresponding rows and columns to the matrix. Indeed, we can treat each electrode as an additional trap with corresponding currents towards/from all of the other traps. For example, one can treat the left and right electrode as $(N+1)$ -th and $(N+2)$ -th traps, correspondingly, so that $i_{N+1,\beta}^\gamma$ and $i_{\beta,N+1}^\gamma$ are the currents from the left electrode to the β -th trap and the current from the β -th trap towards the left electrode; $i_{N+2,\beta}^\gamma$ and $i_{\beta,N+2}^\gamma$ are similar currents for the right electrode.

Stationary state

In many cases, the desired characteristic of a system is the stationary state achieved with time and not the dynamics of its development. In a stationary state, the column vector $\mathbf{p}$ stops changing. Therefore, from (3) it follows that $\hat{\mathbf{Q}}\mathbf{p}^{\text{st}} = 0$. Also, by virtue of its definition, the probability vector $\mathbf{p}$ must always satisfy the additional constraint that the sum of its elements is equal to 1. This means that to find a stationary vector of probabilities, it is necessary to solve a system of $2^N + 1$ linear equations:

$$\begin{aligned} p_1^{\text{st}} + p_2^{\text{st}} + \dots + p_{2^N}^{\text{st}} &= 1 \\ Q_{1,1}p_1^{\text{st}} + Q_{1,2}p_2^{\text{st}} + \dots + Q_{1,2^N}p_{2^N}^{\text{st}} &= 0 \\ Q_{2,1}p_1^{\text{st}} + Q_{2,2}p_2^{\text{st}} + \dots + Q_{2,2^N}p_{2^N}^{\text{st}} &= 0 \\ \vdots &\vdots \\ Q_{2^N,1}p_1^{\text{st}} + Q_{2^N,2}p_2^{\text{st}} + \dots + Q_{2^N,2^N}p_{2^N}^{\text{st}} &= 0. \end{aligned} \tag{5}$$

It can be solved as is or can be converted to a more standard form. Obviously, the system is overdetermined (the number of equations is larger than the number of ‘unknowns’). However, the conventional square non-homogeneous system can also be produced from it in a number of ways. One way is to use the result of adding the first equation to the rest 2^N equations:

$$\begin{aligned} (1 + Q_{1,1})p_1^{\text{st}} + (1 + Q_{1,2})p_2^{\text{st}} + \dots + (1 + Q_{1,2^N})p_{2^N}^{\text{st}} &= 1 \\ (1 + Q_{2,1})p_1^{\text{st}} + (1 + Q_{2,2})p_2^{\text{st}} + \dots + (1 + Q_{2,2^N})p_{2^N}^{\text{st}} &= 1 \\ \vdots &\vdots \\ (1 + Q_{2^N,1})p_1^{\text{st}} + (1 + Q_{2^N,2})p_2^{\text{st}} + \dots + (1 + Q_{2^N,2^N})p_{2^N}^{\text{st}} &= 1. \end{aligned}$$

The system of equations can be expressed in the matrix form:

$$(\hat{\mathbf{J}} + \hat{\mathbf{Q}})\mathbf{p}^{\text{st}} = \mathbf{j},$$

where $\hat{\mathbf{J}}$ is the matrix of ones, $\mathbf{j}$ is the vector of ones. Now, using the matrix notation, the characteristics of stationary state can be expressed explicitly:

$$\mathbf{p}^{\text{st}} = (\hat{\mathbf{J}} + \hat{\mathbf{Q}})^{-1} \mathbf{j}, \quad \bar{\mathbf{n}}^{\text{st}} = \hat{\mathbf{N}}(\hat{\mathbf{Q}} + \hat{\mathbf{J}})^{-1} \mathbf{j}.$$

It is important to note that, despite the mathematical elegance, this way of expressing the solution may not be the most optimal one. Depending on the numerical methods in use, it might be wise to keep the sparsity of matrices. The sparse square non-homogeneous form can be achieved, for example, by simply removing the second equation from the system (5). Now the matrix form of this system of equations is:

$$\hat{\mathbf{Q}}_1 \mathbf{p}^{\text{st}} = \mathbf{j}_1,$$

Figure 1. Illustration of sparsity of matrix $\hat{\mathbf{Q}}$ for $N = 4, 5$ and 6 . White corresponds to zero-valued elements (impossible transitions).

where $\hat{\mathbf{Q}}_1$ is the matrix $\hat{\mathbf{Q}}$ with the elements of the first row substituted with ones, $\mathbf{j}_1$ is the vector, such that the first element is equal to 1 and the rest of the elements are equal to 0. The explicit form of stationary characteristics in this case is:

$$\mathbf{p}^{\text{st}} = \hat{\mathbf{Q}}_1^{-1} \mathbf{j}_1, \quad \bar{\mathbf{n}}^{\text{st}} = \hat{\mathbf{N}} \hat{\mathbf{Q}}_1^{-1} \mathbf{j}_1.$$

It can also be seen that column vector $\mathbf{p}^{\text{st}}$ can be found as the first column of matrix $\hat{\mathbf{Q}}_1^{-1}$, and column vector $\bar{\mathbf{n}}^{\text{st}}$ can be found as the first column of matrix $\hat{\mathbf{N}} \hat{\mathbf{Q}}_1^{-1}$ (due to the associative property of matrix multiplication).

Hop current model

The elementary acts of hopping conduction in the model are:

- Hopping of one charge carrier from an filled trap to an empty one. The rate of such event will be indicated as H ;
- Extraction (ionization and departure) of one carrier from a filled trap towards an electrode. The rate of such event will be indicated as E ;
- Injection of one carrier from an electrode into an empty trap. The rate of such event will be indicated as I .

The probability of observing an elementary act during the time δt is the product of δt and the rate of this act. Thus, the probability of observing the event consisting of L elementary acts during the time δt will be proportional to δt^L . This means that an addition to matrix $\hat{\mathbf{P}}$ from all events consisting of more than one elementary act does not affect the matrix $\hat{\mathbf{Q}}$ according to its definition. Indeed, the limit in (3) gives 0 for any addition with $L > 1$. So, considering the events taking place during the transition from one state to another, we can limit ourselves just to events consisting of one elementary act. However, some transitions are not achievable by only one elementary act. For example, if the state $\mathbf{n}^\alpha$ differs from the state $\mathbf{n}^\beta$ in more than 2 places, the rate of such transition is zero ($Q_{\alpha,\beta} = 0$). The number of possible non-zero elements and their fraction in matrix $\hat{\mathbf{Q}}$ can be easily calculated:

$$N_{\text{nz}} = 2^{N-2} (N^2 + 3N + 4), \quad \rho = \frac{N_{\text{nz}}}{2^{2N}} = \frac{N^2 + 3N + 4}{2^{N+2}}. \quad (6)$$

Thus, even the most general form of matrix $\hat{\mathbf{Q}}$ can be considered sparse (contains mostly zeros) for a reasonably large number of traps, as shown in Figure 1.

Many of the indicated possible non-zero elements can also be treated as zeros due to the fact that the probability of charge transitions is extremely dependent on the distance and the hopping of a trapped charge carrier into a trap not adjacent to it (far jump) is unlikely compared to a jump into the neighboring one. The same applies to the carrier injection from the electrode into an empty trap and extraction from an occupied trap towards the electrode. So, for the simplicity of computations, one can limit oneself to considering only short-range events.

Figure 2. Illustration of different states $\mathbf{n}^\alpha$ and electron transition probability values $P_{\alpha,\beta}$ for $N = 2$ under strong right-to-left electric field.

Examples

In this section we will apply the model to some simple cases of the hopping conduction to illustrate the general mathematical formulation.

Two traps in a strong electric field

Consider a simple case of a 2-trap chain under the strong right-to-left electric field, as illustrated in Figure 2. Under such conditions, we can neglect the probability of electrons moving to the left. In this case, only 3 short-ranged events can happen: injection from the left electrode into the first trap, jumping of the electron trapped in the first trap towards the second trap and extraction of the electron trapped in the second trap towards the right electrode. In this case considered matrices are as follows:

$$\hat{\mathbf{P}} = \begin{bmatrix} 1 - I\delta t & 0 & I\delta t & 0 \\ E\delta t & 1 - E\delta t - I\delta t & 0 & I\delta t \\ 0 & H\delta t & 1 - H\delta t & 0 \\ 0 & 0 & E\delta t & 1 - E\delta t \end{bmatrix}, \quad \hat{\mathbf{Q}} = \lim_{\delta t \rightarrow 0} \frac{\hat{\mathbf{P}} - \hat{\mathbf{I}}}{\delta t} = \begin{bmatrix} -I & 0 & I & 0 \\ E & -E - I & 0 & I \\ 0 & H & -H & 0 \\ 0 & 0 & E & -E \end{bmatrix}, \quad (7)$$

$$\hat{\mathbf{I}}^1 = \begin{bmatrix} 0 & 0 & -qI & 0 \\ 0 & 0 & 0 & 0 \\ qI & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^2 = \begin{bmatrix} 0 & 0 & -qI & 0 \\ 0 & 0 & 0 & qE \\ qI & 0 & 0 & 0 \\ 0 & -qE & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^3 = \begin{bmatrix} 0 & qH & 0 & 0 \\ -qH & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^4 = \begin{bmatrix} 0 & 0 & 0 & 0 \\ 0 & 0 & 0 & qE \\ 0 & 0 & 0 & 0 \\ 0 & -qE & 0 & 0 \end{bmatrix}, \quad (8)$$

where q is the signed carrier charge (equal to the elementary charge modulo).

Solving equations (5) using (7) gives us the stationary probability values of different states:

$$\mathbf{p}^{\text{st}} = \frac{1}{(E + H)(E + I)I + E^2H} [E^2H; EIH; EI(E + I); I^2H]. \quad (9)$$

Average stationary filling can be calculated using the trap filling in different states and found stationary probabilities of these states (9) are

$$\bar{\mathbf{n}}^{\text{st}} = \sum_{\gamma=1}^4 \mathbf{n}^\gamma p_\gamma^{\text{st}} = [0; 0]p_1^{\text{st}} + [0; 1]p_2^{\text{st}} + [1; 0]p_3^{\text{st}} + [1; 1]p_4^{\text{st}} = \frac{1}{(E + H)(E + I)I + E^2H} [(EI + HI + E^2)I; (E + I)HI].$$

The stationary current matrix can be calculated using the state currents (8) and found stationary probabilities (9) is

$$\hat{\mathbf{i}}^{\text{st}} = \sum_{\gamma=1}^4 \hat{\mathbf{i}}^\gamma p_\gamma^{\text{st}} = \frac{(E + I)EIH}{(E + H)(E + I)I + E^2H} \begin{bmatrix} 0 & 1 & -1 & 0 \\ -1 & 0 & 0 & 1 \\ 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \end{bmatrix}$$

Herein, Shockley-Read-Hall-like transport equations (1) describing the dynamics of average occupancy are

$$\begin{aligned} \frac{d\bar{n}_1}{dt} &= (1 - \bar{n}_1)I - \bar{n}_1(1 - \bar{n}_2)H; \\ \frac{d\bar{n}_2}{dt} &= \bar{n}_1(1 - \bar{n}_2)H - \bar{n}_2E. \end{aligned}$$

The stationary state is given by the following nonlinear system of equations:

$$\begin{aligned} I(1 - \bar{n}_1^{\text{st}}) - H\bar{n}_1^{\text{st}}(1 - \bar{n}_2^{\text{st}}) &= 0; \\ H\bar{n}_1^{\text{st}}(1 - \bar{n}_2^{\text{st}}) - E\bar{n}_2^{\text{st}} &= 0. \end{aligned}$$

This nonlinear system of equations can be solved analytically:

$$\begin{aligned} \bar{n}_1^{\text{st}} &= \frac{1}{2} + \frac{\sqrt{(E+H)^2 I^2 + 2EH(E-H)I + E^2 H^2 - (I+H)E}}{2IH}; \\ \bar{n}_2^{\text{st}} &= \frac{1}{2} - \frac{\sqrt{(E+H)^2 I^2 + 2EH(E-H)I + E^2 H^2 - (E+H)I}}{2EH}. \end{aligned}$$

According to the SRH model, the stationary current can be found using average filling:

$$i^{\text{st}} = (1 - \bar{n}_1^{\text{st}})qI = \bar{n}_1^{\text{st}}(1 - \bar{n}_2^{\text{st}})qH = \bar{n}_2^{\text{st}}qE = q \frac{EI + HI + EH - \sqrt{(E+H)^2 I^2 + 2EH(E-H)I + E^2 H^2}}{2H}.$$

Bulk-limited current ($\bar{n}_1 = 1, \bar{n}_N = 0$)

Consider a simple case of uniform linear N -trap chain under a strong right-to-left electric field. Let us also consider, that the current is bulk-limited when $I_{\text{left}} \gg H \gg E_{\text{left}}$ and $E_{\text{right}} \gg H \gg I_{\text{right}}$, i.e. the interfaces between electrodes and a dielectric layer are transparent for charge carriers. In this case, the first trap is filled, and the last one is empty. It is easy to see that this case is identical to the case of uniform linear chain of $N - 2$ traps under a strong electric field when $I = E = H$ (always filled first trap can be treated as the left electrode with $I = H$ and always empty last trap can be treated as the right electrode with $E = H$).

Case of $N = 4$

This case is identical to the case of two-trap chain (the middle two traps) with the corresponding matrices:

$$\begin{aligned} \hat{\mathbf{P}} &= \begin{bmatrix} 1 - H\delta t & 0 & H\delta t & 0 \\ H\delta t & 1 - H\delta t - H\delta t & 0 & H\delta t \\ 0 & H\delta t & 1 - H\delta t & 0 \\ 0 & 0 & H\delta t & 1 - H\delta t \end{bmatrix}, \quad \hat{\mathbf{Q}} = \lim_{\delta t \rightarrow 0} \frac{\hat{\mathbf{P}} - \hat{\mathbf{I}}}{\delta t} = H \begin{bmatrix} -1 & 0 & 1 & 0 \\ 1 & -2 & 0 & 1 \\ 0 & 1 & -1 & 0 \\ 0 & 0 & 1 & -1 \end{bmatrix}, \\ \hat{\mathbf{I}}^1 &= qH \begin{bmatrix} 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & 0 \\ 1 & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^2 = qH \begin{bmatrix} 0 & 0 & -1 & 0 \\ 0 & 0 & 0 & 1 \\ 1 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^3 = qH \begin{bmatrix} 0 & 1 & 0 & 0 \\ -1 & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \\ 0 & 0 & 0 & 0 \end{bmatrix}, \quad \hat{\mathbf{I}}^4 = qH \begin{bmatrix} 0 & 0 & 0 & 0 \\ 0 & 0 & 0 & 1 \\ 0 & 0 & 0 & 0 \\ 0 & -1 & 0 & 0 \end{bmatrix}. \end{aligned}$$

To acquire the dynamic solution, the initial conditions should be given. Let us study the dynamic of filling the initially empty middle traps. In this case $\mathbf{p}(0) = [1; 0; 0; 0]$ and equation (4) gives the following evolution of state probability values:

$$\begin{aligned} p_1(t) &= \frac{1}{5} + \frac{1}{2} \exp(-Ht) + \frac{3 \cos(Ht) + \sin(Ht)}{10} \exp(-2Ht), & (\text{probability of state } [1; 0; 0; 0]) \\ p_2(t) &= \frac{1}{5} - \frac{\cos(Ht) + 2 \sin(Ht)}{5} \exp(-2Ht), & (\text{probability of state } [1; 0; 1; 0]) \\ p_3(t) &= \frac{2}{5} - \frac{2 \cos(Ht) - \sin(Ht)}{5} \exp(-2Ht), & (\text{probability of state } [1; 1; 0; 0]) \\ p_4(t) &= \frac{1}{5} - \frac{1}{2} \exp(-Ht) + \frac{3 \cos(Ht) + \sin(Ht)}{10} \exp(-2Ht), & (\text{probability of state } [1; 1; 1; 0]) \end{aligned}$$

The dynamic solution for average trap filling can be found using the probability values:

$$\begin{aligned} \bar{n}_1 &= 1, \\ \bar{n}_2 &= \frac{3}{5} - \frac{1}{2} \exp(-Ht) - \frac{\cos(Ht) - 3 \sin(Ht)}{10} \exp(-2Ht), \\ \bar{n}_3 &= \frac{2}{5} - \frac{1}{2} \exp(-Ht) + \frac{\cos(Ht) - 3 \sin(Ht)}{10} \exp(-2Ht), \\ \bar{n}_4 &= 0. \end{aligned}$$

Figure 3. Evolution of currents between traps i_{12} , i_{23} and i_{34} for a uniform chain of four traps under strong electric field.

The time dependence of currents between traps on time is as follows:

$$i_{12} = \frac{2}{5}qH \left(1 + \frac{5}{4}\exp(-Ht) + \frac{\cos(Ht) - 3\sin(Ht)}{4}\exp(-2Ht) \right),$$

$$i_{23} = \frac{2}{5}qH \left(1 - \frac{2\cos(Ht) - \sin(Ht)}{2}\exp\{-2Ht\} \right),$$

$$i_{34} = \frac{2}{5}qH \left(1 - \frac{5}{4}\exp(-Ht) + \frac{\cos(Ht) - 3\sin(Ht)}{4}\exp(-2Ht) \right).$$

The evolution of currents between traps i_{12} , i_{23} and i_{34} is shown in Figure 3. One can see that, at the beginning, the current between left traps is quite large, while the currents between right traps are small. In a time $t \approx 5/H$, a stationary state is established, and the currents become the same $i = 0.4qH$. It should be noted that we do not take into account the quantum nature of an electron, because all processes under consideration take place at room temperature and above. Also, electron quantum states are being destroyed during inelastic (de-)trapping acts and the transport is not ballistic. That is why we do not get the conductivity quantum in the obtained solutions.

It is important to note that matrices $\hat{\mathbf{Q}}$ and $\hat{\mathbf{I}}^\gamma$ in the case of linear 4-trap chain under the strong right-to-left electric field with bulk limited current are simply proportional to H . Obviously, this will be the case for the N -trap chain also. A couple of significant conclusions can be drawn from this fact:

- stationary average trap filling does not depend on H value;
- stationary current will have the form $C_i qH$;
- time of establishing a near-stationary solution will have the form C_τ/H .

Here C_i and C_τ are the coefficients that depend on the trap number N only. The values of C_i and C_τ are shown in Figure 4. One can see that C_i tends to the value 0.25 as the number of traps increases for both cases SRH and MJ, but SRH model predicts lower current than Markov jump. Also, Markov jump approach predicts longer transients (steady-state establishment) than the Shockley-Read-Hall-like approach.

Comparison of stationary trap fillings and the current in the case of 4-trap chain for MJ and SRH models is shown in Table 1. One can see, that the Shockley-Read-Hall-like model gives deviations up to 5% from exact values that are calculated in terms of Markov-jump approach. On the one hand, obtained deviations of the current might be smaller than different noises in real experiments, but they might be too large for simulations of high-quality electronic devices.

The same procedure can be carried out for larger trap chains. Comparison of stationary trap filling distributions calculated within SRH and MJ model for trap chains with $N = 4, 8$ and 12 are shown in Figure 5. One can see that the shape of all curves is close and it tends, with the increase on N , to that shown in Figure 3 in Ref. 25 for the continuum case.

Figure 4. The C_i and C_τ coefficients values.

Figure 5. Trap filling distributions, calculated in terms of SRH and MJ approaches for $N = 4, 8$ and 12 .

Discussion

We have developed a discrete model of the charge transport in dielectrics in terms of Markov jump, and it takes into account hops of localized charge carriers between traps in a dielectric medium in strong electric fields with injection-from and extraction-to electrodes (contacts). The developed model is formulated as a matrix differential equation or a system of linear algebraic equations. The dynamic solutions describing the charge transport are found using a matrix exponential. We demonstrated that the solutions can be acquired by manipulations with sparse matrices. This means that the numeric computation of transition processes can be solved quite quickly using optimized algorithms^{26,27}. The developed model is universal and can be applied to a large number of traps distributed in 1D, 2D or 3D systems.

The analytical stationary solutions, that are close to experimentally achievable conditions, are found. The comparison with other theoretical models shows a good agreement²⁵. The developed model, formulated in linear algebraic equations, can be implemented in the computational code using different libraries like BLAS, LAPACK, MKL, SciPy/NumPy etc. Particularly, proposed approach can enhance the current implementation of the leakage current simulations through dielectric layers in Synopsys TCAD software package²⁸. It was shown that the stationary current-voltage characteristics of metal-insulator-semiconductor and metal-insulator-metal structures can be calculated analytically for any trap distribution. Also, the model implemented as a numeric code can be used in simulations of flash, FRAM, RRAM memories and memristor resistive switching with different spatial designs, including vertical and planar ones.

Table 1. Comparison of analytically found stationary trap filling distributions and currents between traps for MJ and SRH models.

	Markov-jump-like	Shockley-Read-Hall-like	Error (%)
$\bar{n}_1^{\text{st}}$	1	1	0
$\bar{n}_2^{\text{st}}$	$\frac{3}{5} = 0.6$	$\frac{\sqrt{5}-1}{2} \approx 0.618$	≈ 3
$\bar{n}_3^{\text{st}}$	$\frac{2}{5} = 0.4$	$\frac{3-\sqrt{5}}{2} \approx 0.382$	≈ -5
$\bar{n}_4^{\text{st}}$	0	0	0
i^{st}	$\frac{2}{5}qH = 0.4qH$	$qH \frac{3-\sqrt{5}}{2} \approx 0.382qH$	≈ -5

References

1. Kar, S. (ed.) *High Permittivity Gate Dielectric Materials*, vol. 43 of *Springer Series in Advanced Microelectronics* (Springer-Verlag Berlin Heidelberg, 2013), 1 edn.
2. Ma, T. P. *et al.* Special reliability features for Hf-based high- κ gate dielectrics. *IEEE Trans. Device Mater. Rel.* **5**, 36–44, DOI: [10.1109/TDMR.2005.845329](https://doi.org/10.1109/TDMR.2005.845329) (2005).
3. Robertson, J. High dielectric constant gate oxides for metal oxide Si transistors. *Reports on Prog. Phys.* **69**, 327–396, DOI: [10.1088/0034-4885/69/2/R02](https://doi.org/10.1088/0034-4885/69/2/R02) (2006).
4. Robertson, J. & Wallace, R. M. High-K materials and metal gates for CMOS applications. *Mater. Sci. Eng. R: Reports* **88**, 1–41, DOI: [10.1016/j.mser.2014.11.001](https://doi.org/10.1016/j.mser.2014.11.001) (2015).
5. Zhao, C., Zhao, C. Z., Taylor, S. & Chalker, P. R. Review on non-volatile memory with high-k dielectrics: Flash for generation beyond 32 nm. *Materials* **7**, 5117–5145, DOI: [10.3390/ma7075117](https://doi.org/10.3390/ma7075117) (2014).
6. Maex, K. *et al.* Low dielectric constant materials for microelectronics. *J. Appl. Phys.* **93**, 8793–8841, DOI: [10.1063/1.1567460](https://doi.org/10.1063/1.1567460) (2003).
7. Wu, C., Y., L., Baklanov, M. R. & K., C. Electrical reliability challenges of advanced low-k dielectrics. *ECS J. Solid State Sci. Technol.* **4**, N3065–N3070, DOI: [10.1149/2.0091501jss](https://doi.org/10.1149/2.0091501jss) (2015).
8. Li, Y. *et al.* Correlation between stress-induced leakage current and dielectric degradation in ultra-porous SiOCH low-k materials. *J. Appl. Phys.* **118**, 164101, DOI: [10.1063/1.4934520](https://doi.org/10.1063/1.4934520) (2015).
9. Gismatulin, A. A., Gritsenko, V. A., Seregin, D. S., Vorotilov, K. A. & Baklanov, M. R. Charge transport mechanism in periodic mesoporous organosilica low-k dielectric. *Appl. Phys. Lett.* **115**, 082904, DOI: [10.1063/1.5113633](https://doi.org/10.1063/1.5113633) (2019).
10. Islamov, D. R., Gritsenko, V. A., Cheng, C. H. & Chin, A. Percolation conductivity in hafnium sub-oxides. *Appl. Phys. Lett.* **105**, 262903, DOI: [10.1063/1.4905308](https://doi.org/10.1063/1.4905308) (2014). [1412.4478](https://doi.org/10.1063/1.4905308).
11. Ambrogio, S. *et al.* Statistical fluctuations in HfO_x resistive-switching memory: Part I — set/reset variability. *IEEE Trans. Electron Devices* **61**, 2912–2919, DOI: [10.1109/ted.2014.2330200](https://doi.org/10.1109/ted.2014.2330200) (2014).
12. Voronkovskii, V. A., Aliev, V. S., Gerasimova, A. K. & Islamov, D. R. Influence of HfO_x composition on hafnium oxide-based memristor electrical characteristics. *Mater. Res. Express* **5**, 016402, DOI: [10.1088/2053-1591/aaa099](https://doi.org/10.1088/2053-1591/aaa099) (2018).
13. Fowler, R. H. & Nordheim, L. Electron emission in intense electric fields. *Proc. Royal Soc. Lond. A: Math. Phys. Eng. Sci.* **119**, 173–181, DOI: [10.1098/rspa.1928.0091](https://doi.org/10.1098/rspa.1928.0091) (1928).
14. Murphy, E. L. & Good, J., R. H. Thermionic emission, field emission, and the transition region. *Phys. Rev.* **102**, 1464–1473, DOI: [10.1103/physrev.102.1464](https://doi.org/10.1103/physrev.102.1464) (1956).
15. Roberts, G. G. & Polanco, J. I. Thermally assisted tunnelling in dielectric films. *physica status solidi (a)* **1**, 409–420, DOI: [10.1002/pssa.19700010306](https://doi.org/10.1002/pssa.19700010306) (1970).
16. Schottky, W. Über den einfluß von strukturwirkungen, besonders der thomsonschen bildkraft, auf die elektronenemission der metalle. *Physikalische Zeitschrift* **15**, 872–878 (1914).
17. Khairurrijal, Mizubayashi, W., Miyazaki, S. & Hirose, M. Analytic model of direct tunnel current through ultrathin gate oxides. *J. Appl. Phys.* **87**, 3000–3005, DOI: [10.1063/1.372290](https://doi.org/10.1063/1.372290) (2000).

18. Frenkel, J. On the theory of electric breakdown of dielectrics and electronic semiconductors. *Tech. Phys. USSR* **5**, 685–695 (1938).
19. Frenkel, J. On pre-breakdown phenomena in insulators and electronic semi-conductors. *Phys. Rev.* **54**, 647–648, DOI: [10.1103/PhysRev.54.647](https://doi.org/10.1103/PhysRev.54.647) (1938).
20. Makram-Ebeid, S. & Lannoo, M. Quantum model for phonon-assisted tunnel ionization of deep levels in a semiconductor. *Phys. Rev. B* **25**, 6406–6424, DOI: [10.1103/PhysRevB.25.6406](https://doi.org/10.1103/PhysRevB.25.6406) (1982).
21. Hill, R. M. Poole-Frenkel conduction in amorphous solids. *Philos. Mag.* **23**, 59–86, DOI: [10.1080/14786437108216365](https://doi.org/10.1080/14786437108216365) (1971).
22. Adachi, H., Shibata, Y. & Ono, S. On electronic conduction through evaporated silicon oxide films. *J. Phys. D: Appl. Phys.* **4**, 988–994 (1971).
23. Nasyrov, K. A. & Gritsenko, V. A. Charge transport in dielectrics via tunneling between traps. *J. Appl. Phys.* **109**, 093705, DOI: [10.1063/1.3587452](https://doi.org/10.1063/1.3587452) (2011).
24. Vishnyakov, A. V., Novikov, Y. N., Gritsenko, V. A. & Nasyrov, K. A. The charge transport mechanism in silicon nitride: Multi-phonon trap ionization. *Solid-State Electron.* **53**, 251–255, DOI: [10.1016/j.sse.2008.07.005](https://doi.org/10.1016/j.sse.2008.07.005) (2009).
25. Pil'nik, A. A., Chernov, A. A. & Islamov, D. R. Charge transport mechanism in dielectrics: drift and diffusion of trapped charge carriers. *Sci. Reports* **10**, 15759, DOI: [10.1038/s41598-020-72615-1](https://doi.org/10.1038/s41598-020-72615-1) (2020).
26. Fasi, M. & Higham, N. J. An arbitrary precision scaling and squaring algorithm for the matrix exponential. *SIAM J. on Matrix Analysis Appl.* **40**, 1233–1256, DOI: [10.1137/18m1228876](https://doi.org/10.1137/18m1228876) (2019).
27. Sherlock, C. Direct statistical inference for finite markov jump processes via the matrix exponential (2020). [1809.07110](https://arxiv.org/abs/1809.07110).
28. Synopsys. *Sentaurus™ Device User Guide*. Synopsys, Inc.

Acknowledgements

This work was supported by the Russian Science Foundation (grant No. 16-19-00002). The numeric calculations were performed using the computing clusters of the Novosibirsk State University and ISP SB RAS.

Author contributions statement

D.R.I. proposed and supervised the project. A.A.P. developed the mathematical model, found analytical solutions and conducted the numerical simulations. A.A.P. and D.R.I. analysed the mathematical model. A.A.Ch. analysed the found analytical solutions and took part in the discussions. All authors wrote and reviewed the manuscript.

Ethics declarations

Competing interests

The authors declare no competing interests.

Figures

Figure 1

Illustration of sparsity of matrix $\hat{Q}$ for $N = 4, 5$ and 6 . White corresponds to zero-valued elements (impossible transitions).

Figure 2

Illustration of different states n_a and electron transition probability values P_{ab} for $N = 2$ under strong right-to-left electric field.

Figure 3

Evolution of currents between traps i_{12} , i_{23} and i_{34} for a uniform chain of four traps under strong electric field.

Figure 4

The C_i and C_τ coefficients values.

Figure 5

Trap filling distributions, calculated in terms of SRH and MJ approaches for $N = 4, 8$ and 12 .